PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Group Art Unit: 2106

Mark D. Owen and James N. O'Brien

Application No. 08/276,797

Filed: July 18, 1994

For: Ultraviolet laser system for forming vias in multi-layered

TARGETS

Examiner: Gregory L. Mills

SUBSTITUTE DECLARATION OF MARK D. OWEN CONCERNING AUTHORSHIP

TO THE ASSISTANT COMMISSIONER FOR PATENTS:

- I, Mark D. Owen, declare as follows:
- I am an inventor named in the aboveidentified patent application.
- 2. Mr. Rodger Dwight, the Communications
 Manager at Electro Scientific Industries, Inc., was
 responsible for organizing the content and layout of
 the Fall 1993 Laser Pulse reference published by
 Electro Scientific Industries, Inc.
- 3. I am a co-author of the Fall 1993

 LaserPulse reference published by Electro Scientific Industries, Inc., and I edited the "4420" brochure. I wrote the text of "UV Laser Micromachining Applications Continue to Grow," appearing on pages 6 and 7, of the Fall 1993 LaserPulse reference and provided all of the photographs appearing in the reference to Mr. Dwight.

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- 4. The text of pages 6 and 7 is based on data and photographs derived from experiments conducted by me and Mr. James N. O'Brien. Mr. O'Brien and I invented the subject matter disclosed on these pages.
- 5. Mr. O'Brien and I also prepared the examples for the photographs appearing in the "4420" brochure. The information and pulse parameters that are contained in the brochure that pertain to via drilling are subject matter derived from our
 - 6. I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under section 1001 of Title 18 of the Unites States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.